

L Number	Hits	Search Text	DB	Time stamp
4	188327	438/\$.ccls. or 702/\$.ccls. or 700/29-31,46,52,93,95-97,108-110,117,119,121-123,160,174-178.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 16:39
5	44804	(set\$3 or format\$4 or initial\$8 or initiat\$4 or re-set\$3 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$3 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 16:49
6	5389	(recipe or ((process\$3 or operat\$4 or manufactur\$3 or production or fabricat\$3) near3 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient))) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 16:49
7	204165	(tool\$3 or equipment or etch\$3 or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3) near4 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 16:53
8	21176	(setting or seting or initial\$8 or initiat\$4 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 16:43
9	11207	(recipe or ((process\$3 or operat\$4 or manufactur\$3 or production or fabricat\$3) near3 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient))) with (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 16:41
10	43267	(setting or seting or preparing or initializ\$5 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4 or correct\$3 or tweak\$3 or tun\$4 or computing or calculat\$3 or recomput\$6 or recalcultat\$4 or re-comput\$6 or re-calculat\$4 or trigger\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 17:06
11	6468	(recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4))) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 17:00
12	896	((setting or seting or preparing or initializ\$5 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4 or correct\$3 or tweak\$3 or tun\$4 or computing or calculat\$3 or recomput\$6 or recalcultat\$4 or re-comput\$6 or re-calculat\$4 or trigger\$3) near3 (recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4)))) with (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 16:52

13	43566	((setting or seting or preparing or initializ\$5 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4 or correct\$3 or tweak\$3 or tun\$4 or computing or calculat\$3 or recomput\$6 or recalculat\$4 or re-comput\$6 or re-calculat\$4 or trigger\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))) or (((setting or seting or preparing or initializ\$5 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4 or correct\$3 or tweak\$3 or tun\$4 or computing or calculat\$3 or recomput\$6 or recalculat\$4 or re-comput\$6 or re-calculat\$4 or trigger\$3) near3 (recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4)))) with (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 16:52
14	132920	(tool\$3 or equipment or etch\$3 or RIE or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3 or pad) near3 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or preventivemaintenanc\$3 or preventive-maintenanc\$3 or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or conditioning or conditioned or dressing or re-dressing or redressing or event or revitaliz\$8 or malfunction\$3 or degrad\$6)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 16:57
15	1349	((target\$3 or specification) near3 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or preventivemaintenanc\$3 or preventive-maintenanc\$3 or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or conditioning or conditioned or dressing or re-dressing or redressing or event or revitaliz\$8 or malfunction\$3 or degrad\$6)) with (tool\$3 or equipment or etch\$3 or RIE or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3 or pad)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 16:58
16	1333	((control\$4) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC) with (recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 17:01
17	133580	((tool\$3 or equipment or etch\$3 or RIE or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3 or pad) near3 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or preventivemaintenanc\$3 or preventive-maintenanc\$3 or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or conditioning or conditioned or dressing or re-dressing or redressing or event or revitaliz\$8 or malfunction\$3 or degrad\$6)) or (((target\$3 or specification) near3 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or preventivemaintenanc\$3 or preventive-maintenanc\$3 or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or conditioning or conditioned or dressing or re-dressing or redressing or event or revitaliz\$8 or malfunction\$3 or degrad\$6)) with (tool\$3 or equipment or etch\$3 or RIE or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3 or pad))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 17:01

18	6995	((recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4))) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))) or (((control\$4) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC) with (recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4))))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 17:02
19	249	(((setting or seting or preparing or initializ\$5 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4 or correct\$3 or tweak\$3 or tun\$4 or computing or calculat\$3 or recomput\$6 or recalcultat\$4 or re-comput\$6 or re-calculat\$4 or trigger\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))) or (((setting or seting or preparing or initializ\$5 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4 or correct\$3 or tweak\$3 or tun\$4 or computing or calculat\$3 or recomput\$6 or recalcultat\$4 or re-comput\$6 or re-calculat\$4 or trigger\$3) near3 (recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4)))) with (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))) and (((tool\$3 or equipment or etch\$3 or RIE or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3 or pad) near3 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or preventivemaintenanc\$3 or preventive-maintenanc\$3 or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or conditioning or conditioned or dressing or re-dressing or redressing or event or revitaliz\$8 or malfunction\$3 or degrad\$6)) or (((target\$3 or specification) near3 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or preventivemaintenanc\$3 or preventive-maintenanc\$3 or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or conditioning or conditioned or dressing or re-dressing or redressing or event or revitaliz\$8 or malfunction\$3 or degrad\$6)) with (tool\$3 or equipment or etch\$3 or RIE or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3 or pad))) and (((recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4))) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))) or (((control\$4) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC) with (recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4))))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 17:02

20	8537	((setting or seting or preparing or initializ\$5 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4 or correct\$3 or tweak\$3 or tun\$4 or computing or calculat\$3 or recomput\$6 or recalculat\$4 or re-comput\$6 or re-calculat\$4 or trigger\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4) or recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4)))) with (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or preventivemaintenanc\$3 or preventive-maintenanc\$3 or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or conditioning or conditioned or dressing or re-dressing or redressing or event or revitaliz\$8 or malfunction\$3 or degrad\$6)	USPAT; US-PGPUB; EPO, JPO; DERWENT; IBM_TDB	2004/07/14 20:54
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21	95	<p>(((((setting or seting or preparing or initializ\$5 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4 or correct\$3 or tweak\$3 or tun\$4 or computing or calculat\$3 or recomput\$6 or recalculat\$4 or re-comput\$6 or re-calculat\$4 or trigger\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4)))) or (((setting or seting or preparing or initializ\$5 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4 or correct\$3 or tweak\$3 or tun\$4 or computing or calculat\$3 or recomput\$6 or recalculat\$4 or re-comput\$6 or re-calculat\$4 or trigger\$3) near3 (recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4)))) with (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4)))) and (((tool\$3 or equipment or etch\$3 or RIE or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3 or pad) near3 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or preventivemaintenanc\$3 or preventive-maintenanc\$3 or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or conditioning or conditioned or dressing or re-dressing or redressing or event or revitaliz\$8 or malfunction\$3 or degrad\$6)) or (((target\$3 or specification) near3 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or preventivemaintenanc\$3 or preventive-maintenanc\$3 or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or conditioning or conditioned or dressing or re-dressing or redressing or event or revitaliz\$8 or malfunction\$3 or degrad\$6)) with (tool\$3 or equipment or etch\$3 or RIE or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3 or pad))) and (((recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4)))) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4)))) or (((control\$4) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC) with (recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4)))))) and (((setting or seting or preparing or initializ\$5 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4 or correct\$3 or tweak\$3 or tun\$4 or computing or calculat\$3 or recomput\$6 or recalculat\$4 or re-comput\$6 or re-calculat\$4 or trigger\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4) or recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4)))) with (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or preventivemaintenanc\$3 or preventive-maintenanc\$3 or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or conditioning or conditioned or dressing or re-dressing or redressing or event or revitaliz\$8 or malfunction\$3 or degrad\$6))</p>	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 20:27
23	2	5546312.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 20:27

24	155	((setting or seting or preparing or initializ\$5 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4 or correct\$3 or tweak\$3 or tun\$4 or computing or calculat\$3 or recomput\$6 or recalculat\$4 or re-comput\$6 or re-calculat\$4 or trigger\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4) or recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4)))) with (clean\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 20:55
25	16	(438/\$.ccls. or 702/\$.ccls. or 700/29-31,46,52,93,95-97,108-110,117,119,121-123,160,174-178.ccls.) and (((setting or seting or preparing or initializ\$5 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4 or correct\$3 or tweak\$3 or tun\$4 or computing or calculat\$3 or recomput\$6 or recalculat\$4 or re-comput\$6 or re-calculat\$4 or trigger\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4) or recipe or ((process\$3 or operat\$8 or manufactur\$3 or production or fabricat\$3 or assembly) near2 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient or execut\$4)))) with (clean\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/14 20:55
-	5756	((set\$3 or format\$4 or initial\$8 or initiat\$4 or re-set\$3 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$3 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC)) with (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 19:35
-	586	((tool\$3 or equipment or etch\$3 or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3) near4 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event)) and (((set\$3 or format\$4 or initial\$8 or initiat\$4 or re-set\$3 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$3 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC)) with (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 18:26
-	75	((recipe or ((process\$3 or operat\$4 or manufactur\$3 or production or fabricat\$3) near3 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient))) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC)) and (((tool\$3 or equipment or etch\$3 or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3) near4 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event)) and (((set\$3 or format\$4 or initial\$8 or initiat\$4 or re-set\$3 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$3 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC)) with (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 18:27
-	2	((set\$3 or format\$4 or initial\$8 or initiat\$4 or re-set\$3 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$3 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC)) same ((replac\$3 or chang\$3) near2 pad\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 19:36
-	14	("4833617" "5356513" "5367465" "5471403" "5486129" "5510652" "5514245" "5526293" "5599423" "5637031" "5655110" "5665202" "5759918" "5836807").PN.	USPAT	2004/07/13 19:38

-	3118	((setting or seting or initial\$8 or initiat\$4 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))) with (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:08
-	276	((tool\$3 or equipment or etch\$3 or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3) near4 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event)) and (((setting or seting or initial\$8 or initiat\$4 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))) with (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:10
-	5457	(recipe or ((process\$3 or operat\$4 or manufactur\$3 or production or fabricat\$3) near3 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient))) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:10
-	42	((tool\$3 or equipment or etch\$3 or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3) near4 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event)) and (((setting or seting or initial\$8 or initiat\$4 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))) with (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event))) and ((recipe or ((process\$3 or operat\$4 or manufactur\$3 or production or fabricat\$3) near3 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient))) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:11
-	65	((tool\$3 or equipment or etch\$3 or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3) near4 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event)) and (((setting or seting or initial\$8 or initiat\$4 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4))) with (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event))) and ((recipe or ((process\$3 or operat\$4 or manufactur\$3 or production or fabricat\$3) near3 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient))) with (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:40
-	1	"6361406".PN.	USPAT	2004/07/13 21:40

-	16	(((tool\$3 or equipment or etch\$3 or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3) near4 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event)) and (((setting or seting or initial\$8 or initiat\$4 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4)))) with (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event))) and ((recipe or ((process\$3 or operat\$4 or manufactur\$3 or production or fabricat\$3) near3 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient))) with (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4)))) not (((recipe or ((process\$3 or operat\$4 or manufactur\$3 or production or fabricat\$3) near3 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient))) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC)) and (((tool\$3 or equipment or etch\$3 or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3) near4 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event)) and (((set\$3 or format\$4 or initial\$8 or initiat\$4 or re-set\$3 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$3 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC)) with (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event))))	USPAT	2004/07/13 21:40
-	30	(((tool\$3 or equipment or etch\$3 or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3) near4 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event)) and (((setting or seting or initial\$8 or initiat\$4 or re-set\$4 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$4 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4)))) with (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event))) and ((recipe or ((process\$3 or operat\$4 or manufactur\$3 or production or fabricat\$3) near3 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient))) with (model\$3 or simulat\$3 or emulat\$3 or SPC or (statistic\$4 near2 control\$4)))) not (((recipe or ((process\$3 or operat\$4 or manufactur\$3 or production or fabricat\$3) near3 (instruct\$3 or command\$3 or parameter or list\$3 or ingredient))) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC)) and (((tool\$3 or equipment or etch\$3 or polish\$3 or deposit\$3 or lithograph\$6 or stepper or photolithograph\$6 or photo-lithograph\$6 or RTP or (rapid adj2 thermal) or implant\$8 or CMP or CVD or vapordeposit\$3) near4 (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event)) and (((set\$3 or format\$4 or initial\$8 or initiat\$4 or re-set\$3 or re-format\$4 or re-initial\$8 or re-initiat\$4 or reset\$3 or reformat\$4 or reinitial\$8 or reinitiat\$4 or start\$3 or re-start\$3 or restart\$3) near3 (model\$3 or simulat\$3 or emulat\$3 or SPC)) with (drift\$4 or slip\$5 or shift\$3 or deviat\$3 or maintenanc\$3 or pm or replac\$6 or error or fault\$3 or misprocess\$3 or mistarget or condition\$3 or event))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:45

-	99	(retun\$3 or re-tun\$3) near3 (initial\$8 or trigger\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:51
-	82	(retun\$3 or re-tun\$3) near3 (initial\$8)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:50
-	37	(retun\$3 or re-tun\$3) near2 (initial\$8)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:46
-	19	(retun\$3 or re-tun\$3) near1 (initial\$8)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:50
-	335	((re-set\$4 or re-format\$4 or reset\$4 or reformat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4) near1 (initial\$8)) and (438/\$.ccls. or 702/\$.ccls. or 700/29-31,46,52,93,95-97,108-110,117,119,121-123,160,174-178.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:50
-	7	((re-set\$4 or re-format\$4 or reset\$4 or reformat\$4 or re-start\$3 or restart\$3 or retun\$4 or re-tun\$4 or re-tweak\$3 or retweak\$3 or re-correct\$4 or recorrect\$4) near1 (initial\$8)).ab. and (438/\$.ccls. or 702/\$.ccls. or 700/29-31,46,52,93,95-97,108-110,117,119,121-123,160,174-178.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:50
-	0	((retun\$3 or re-tun\$3) near3 (initial\$8)) and (438/\$.ccls. or 702/\$.ccls. or 700/29-31,46,52,93,95-97,108-110,117,119,121-123,160,174-178.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:51
-	82	((retun\$3 or re-tun\$3) near3 (initial\$8)) and ((retun\$3 or re-tun\$3) near3 (initial\$8 or trigger\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:51
-	0	((retun\$3 or re-tun\$3) near3 (initial\$8)) and (438/\$.ccls. or 702/\$.ccls. or 700/29-31,46,52,93,95-97,108-110,117,119,121-123,160,174-178.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:51
-	0	((retun\$3 or re-tun\$3) near3 (initial\$8 or trigger\$3)) and (438/\$.ccls. or 702/\$.ccls. or 700/29-31,46,52,93,95-97,108-110,117,119,121-123,160,174-178.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 21:51
-	2	((retun\$3 or re-tun\$3) near3 (initial\$8 or set\$4 or reset\$4)) and (438/\$.ccls. or 702/\$.ccls. or 700/29-31,46,52,93,95-97,108-110,117,119,121-123,160,174-178.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 22:06
-	46	((recipe) near2 (operat\$4 near2 parameter)) and (438/\$.ccls. or 702/\$.ccls. or 700/29-31,46,52,93,95-97,108-110,117,119,121-123,160,174-178.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 22:08

-	45	((recipe) near2 ((operation or operating) near2 parameter)) and (438/\$.ccls. or 702/\$.ccls. or 700/29-31,46,52,93,95-97,108-110,117,119,121-123,160,174-178.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 22:09
-	4	((recipe) near2 ((operation or operating) adj parameter)) and (438/\$.ccls. or 702/\$.ccls. or 700/29-31,46,52,93,95-97,108-110,117,119,121-123,160,174-178.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 22:10
-	5	((recipe) near2 ((operation or operating) adj parameter)) and (700/\$.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/13 22:10